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(FILE 'HOME' ENTERED AT 12:42:59 ON 15 NOV 2007)

FILE 'CA' ENTERED AT 12:43:08 ON 15 NOV 2007

- L1 3317 S GALVANOMET? OR GALVANOMODULAT? OR GALVANOOSCIL? OR GALVANOSCIL?
- L2 30563 S (CURRENT OR GALVANO) (2A) (DYNAMIC OR VARY? OR VARIA? OR SCAN? OR MODULAT? OR OSCIL? OR SWEEP? OR STEP? OR PULSE# OR PULSING)
- L3 111 S L1-2 AND RAMAN
- L4 549 S L1-2 AND (ROUGH? OR FINELY DIVIDED)
- L5 2 S L4 AND (ADATOM? OR ADLAYER?)
- L6 116 S L4 AND (CURRENT (2A) DENSITY OR C D)
- L7 33 S L4 AND (PORE OR POROUS OR POROSITY)
- L8 · 56 S L4 AND (SILVER OR AG OR GOLD OR AU)
- L9 41 S L1-2 AND (SER OR SERS OR SURFACE (1A) ENHANC?)
- L10 321 S L3, L5-9
- L11 231 S L10 AND PY<2004
- L12 4 S L10 NOT L11 AND PATENT/DT AND RAMAN
- L13 169 S L11 AND ENGLISH/LA
- L14 22 S L11 NOT L13 AND (RAMAN OR UNSTEADY OR PATENT/DT)
- L15 195 S L12-14
- => d bib, ab, kwic 115 1-195
- L15 ANSWER 16 OF 195 CA COPYRIGHT 2007 ACS on STN
- AN 139:388126 CA
- TI Subfemtosecond pulse generation by nonadiabatic molecular modulation
- AU Wu, Jian; Zeng, Heping
- CS Department of Physics, Key Laboratory of Optical and Magnetic Resonance Spectroscopy, East China Normal University, Shanghai, 200062, Peop. Rep. China
- SO Applied Physics Letters (2003), 83(11), 2127-2129
- The authors suggest a technique to generate subfemtosecond pulse train in a Raman generator driven by three sufficiently intense single-mode laser beams whose carrier frequencies are tuned off the Raman resonance with two different two-photon detunings. The Raman interaction establishes a mol. modulation through a nonadiabatic process. The simulation based on the 1st fundamental vibrational Raman transition of solid H indicates that subfemtosecond pulse train can be generated when the signs of the two-photon detunings are opposite. This opens an exptl. feasible way to observe enhanced generation of broadband Raman sidebands as well as compression of the phase-locked Raman sidebands into subfemtosecond pulse trains in the same Raman media with above- and below-resonance Raman excitations.
- L15 ANSWER 32 OF 195 CA COPYRIGHT 2007 ACS on STN
- AN 138:177227 CA
- TI Electrochemically Roughened Rhodium Electrode as a Substrate for **Surface-enhanced Raman** Spectroscopy
- AU Ren, Bin; Lin, Xu-feng; Yan, Jia-wei; Mao, Bing-wei; Tian, Zhong-qun
- CS Department of Chemistry State Key Laboratory for Physical Chemistry of Solid Surfaces, Xiamen University, Xiamen, 361005, Peop. Rep. China
- SO Journal of Physical Chemistry B (2003), 107(4), 899-902
- AB A method to produce a substrate suitable for surface-enhanced Raman

enhanced Raman scattering (SERS) active Rh electrode with good stability, reversibility, and ease of prepn. can be obtained by the control-current electrochem. roughening method. The surface enhancement factor is 3 orders of magnitude. Such kind of enhancement allows the study of not only some mols. of large Raman cross-section (e.g., pyridine) but also other mols. of very small Raman cross-section (like CO). The Rh surface can be used as a useful substrate for the combined electrochem. and Raman study of some systems that are both of fundamental and application interest.

- L15 ANSWER 59 OF 195 CA COPYRIGHT 2007 ACS on STN
- AN 135:11491 CA
- TI Fabrications and characterizations of porous silicon by two-step techniques. II. **Pulse current** application
- AU Cheng, Xuan; Liu, Feng-ming; Wen, Zuo-xin; Lin, Chang-jian; Tian, Zhong-qun; Xue, Ru
- CS Department of Chemistry, Xiamen University, Xiamen, 361005, Peop. Rep. China
- SO Dianhuaxue (**2001**), 7(1), 78-84
- AB Porous silicon structures were formed by two-step technique consisting of **pulse current** applications in 1:1 hydrofluoric acid and ethanol solns. and chem. oxidn. in 20% nitric acid solns. Their surface morphologies and optical properties were characterized by scanning electron microscope (SEM) and **Raman** spectrometer, and compared with those obtained by const. current application. More uniform pore formation on p(100) silicon wafers was obsd. by **pulse current** application. Illumination with an UV lamp during the **pulse current** application accelerated the macropore formation, accordingly, the optical properties were changed.
- L15 ANSWER 61 OF 195 CA COPYRIGHT 2007 ACS on STN
- AN 134:345846 CA
- TI Rhodium as a ubiquitous substrate for **surface enhanced Raman** spectroscopy
- AU Ren, Bin; Lin, Xu-feng; Tian, Zhong-qun
- CS Department of Chemistry and State Key Lab for Phys. Chem. of Solid Surfaces, Xiamen University, Xiamen, 361005, Peop. Rep. China
- SO Dianhuaxue (2001), 7(1), 55-58
- AB A method is presented for roughening the surface of Rh to make it applicable for surface-enhanced Raman spectroscopy (SERS). The deep oxidn. of the Rh surface was carried out by electrochem. etching at a pulse current between -30 50 mA with a frequency of 200-800 Hz. The applicability for SERS was tested for roughened Rh surfaces on which pyridine or CO was adsorbed. The corresponding SERS spectra are depicted and discussed and the applicability for SERS was proven.
- L15 ANSWER 62 OF 195 CA COPYRIGHT 2007 ACS on STN
- AN 134:286919 CA
- TI Recent trends in electrocatalysis adsorption of oxygen species on Ag electrodes and the mechanism of H2O2 reduction
- AU Doblhofer, Karl; Flatgent, Georg; Radhakrishnan, Ganesan; Pettinger, Bruno; Savinova, Elena; Wasle, Sabine

- CS Fritz-Haber-Institut der Max-Planck-Gesellschaft, Berlin, D-14195, Germany
- SO Transactions of the SAEST (1999), 34(3-4), 88-92
- In-situ surface enhanced Raman spectroscopy (SERS) and ex-situ XPS can AΒ be employed successfully for detecting oxygen-contg. species on single crystal silver electrodes. From such expts. the mechanism of Ag(111) premonolayer oxidn. in alk. electrolyte is derived. The cathodic redn. of hydrogen peroxide on silver electrodes in acidic electrolyte can proceed by two parallel mechanisms. First, by the normal mechanism that is discussed in the literature, 2nd, by a novel mechanism that operates at a significantly smaller overvoltage. This 2nd mechanism involves as an activating species adsorbed hydroxide, OHads, as known from premonolayer oxidn. of the electrode. Since this adsorbate is unstable in the acidic electrolyte, a nonequil. coverage is generated in cathodic H2O2 redn., where OHads is known to form as an intermediate. Consequently, the 2nd H2O2 redn. mechanism is considered to be of the autocatalytic type. It yields an N-shaped current/voltage curve and current oscillations. The conclusions are tested by model calcns.
- L15 ANSWER 70 OF 195 CA COPYRIGHT 2007 ACS on STN
- AN 133:229600 CA
- TI A method and an apparatus for electrochemical **roughening** a support for light-sensitive layers
- IN Haby, Georg; Haas, Raimund; Gartmann, Uwe; Hultzsch, Gunter; Joerg, Klaus; Kaden, Jorg; Idstein, Hermann
- PA Agfa-Gevaert A.-G., Germany
- SO Eur. Pat. Appl., 14 pp.
- PI EP 1033420 A1 20000906 EP 2000-104028 20000226 US 6423206 B1 20020723 US 2000-516805 20000301
- PRAI DE 1999-19908884 A 19990302
- AB To improve (minimize) the **roughness** of the carrier which is transported through an electrolyte in which the electrochem. **roughening** is carried out, the **pulsed current** or a control of the a.c. or d.c. was used. The **c.d.** between the rotating electrode and the second carrier was changed in a way that it had a lower value in the inner-part of the **roughening** zone. An addnl. rotating electrode was set on the second carrier. The first rotating electrode had a rounded contour which corresponded to the cell design. A detailed description of a design of the system and its scheme are provided.
- L15 ANSWER 75 OF 195 CA COPYRIGHT 2007 ACS on STN
- AN 132:314954 CA
- TI Electrodeposition of **gold** from a sulphite bath by direct and **pulse currents:** applications to opto-electronic devices
- AU Roy, S.; Caprodossi, S.
- CS Department of Chemical and Process Engineering, University of Newcastle-upon-Tyne, NE1 7RU, UK
- SO Proceedings Electrochemical Society (2000), 99-34(Electrochemical Technology Applications in Electronics), 145-156
- The applicability of **gold** electrodeposition from a sulfite electrolyte for the manuf. of opto-electronic devices was studied. Electrodeposition of **gold** was carried out by direct and **pulse currents** at a rotating cylinder Hull type cell and a rectangular flow cell. The

rotating cylinder Hull cell was used to det. the effect of fluid hydrodynamics, c.d., and current waveform on the microstructure of gold deposits in the lab. Electrochem. and hydrodynamic parameters that yielded best results in lab. expts. were then used to electrodeposit gold on wafers placed in a rectangular flow cell. The microstructure of gold was dependent on applied c.d. during d.c. deposition, but it was dependent on steady state and nonsteady state mass transfer during pulse current plating.

- L15 ANSWER 79 OF 195 CA COPYRIGHT 2007 ACS on STN AN 132:186921 CA
- TI Optical properties of multilayered porous silicon
- AU Setzu, S.; Ferrand, P.; Romestain, R.
- CS Universite Joseph Fourier CNRS (UMR 5588), Laboratoire de Spectrometrie Physique, St Martin d'Heres, 38402, Fr.
- SO Materials Science & Engineering, B: Solid-State Materials for Advanced Technology (2000), B69-70, 34-42
- The authors present a short review of some optical devices based on multilayered porous Si, which can be easily obtained by varying the formation current during the etching process. These include Bragg reflectors and Fabry-Perot microcavities, which can be adjusted from the visible to the near IR. The interface roughness, tragic in the case of multilayers, was studied. It can be drastically reduced when changing the electrolyte viscosity. The high reflectivities obtained in this way are measured by Cavity Ring-Down Spectroscopy. Problems occurring when realizing thin layers and an efficient way to adjust precisely the optical thicknesses of the thin layers constituting the multilayered structure are also presented. Finally the authors present a method of calcn. of the emission which takes absorption into account and is able to explain the angular dependence of the luminescence.
- L15 ANSWER 86 OF 195 CA COPYRIGHT 2007 ACS on STN
- AN 131:231750 CA
- TI A study of surface finishing in **pulse current** electroforming of nickel by utilizing different shaped waveforms
- AU Wong, K. P.; Chan, K. C.; Yue, T. M.
- CS Hung Hom, Department of Manufacturing Engineering, The Hong Kong Polytechnic University, Kowloon, Peop. Rep. China
- SO Surface and Coatings Technology (1999), 115(2-3), 132-139
- This paper studies exptl. and theor. the effect of different types of shaped waveform on the surface finish of Ni electroforms in **pulse** current electroforming. The quality of the electroforms, in terms of surface roughness improvement, influenced by the types of waveform is of the order of ramp and triangular both with relaxation timerectangularramp and triangular sawtooth. At the same cathodic peak c.d., pulse period, and a fixed electrodeposition time or electrodeposition thickness, the surface roughness can be reduced by ≤2 to 3 times when a relaxation time was used in the cases of ramp and triangular waveforms. These results are supported by the theor. predictions and the study of the surface morphol. of the electroforms by
- L15 ANSWER 88 OF 195 CA COPYRIGHT 2007 ACS on STN

SEM.

- TI A galvanostatic study of the electrodeposition of polypyrrole into porous silicon
- AU Moreno, J. D.; Marcos, M. L.; Agullo-Rueda, F.; Guerrero-Lemus, R.; Martin-Palma, R. J.; Martinez-Duart, J. M.; Gonzalez-Velasco, J.
- CS Departamento de Fisica Aplicada C-12, Universidad Autonoma de Madrid, Madrid, 28049, Spain
- SO Thin Solid Films (1999), 348(1,2), 152-156
- AB Polypyrrole was electrodeposited in the interior of the pores that form the porous silicon structure, and a very significant increase of the elec. cond. of the samples was obsd. Micro-Raman spectroscopy expts. have allowed the authors to measure the amt. of polymer as a function of the distance from the outer porous silicon surface. The degree of filling by the polymer is highly dependent on the electropolymn. conditions, particularly the c.d. applied.
- L15 ANSWER 99 OF 195 CA COPYRIGHT 2007 ACS on STN
- AN 129:46640 CA
- TI In situ probing of interfacial processes in the electrodeposition of copper by confocal **Raman** microspectroscopy
- AU Texier, F.; Servant, L.; Bruneel, J. L.; Argoul, F.
- CS Centre de Recherche Paul Pascal, Pessac, 33600, Fr.
- SO Journal of Electroanalytical Chemistry (1998), 446(1-2), 189-203
- Confocal Raman microspectroscopy is applied to the in situ probing of interfacial processes in pulsed-current copper electrodeposition. This technique provides time-resolved characterization of the vibrational spectra of sulfate ions whenever in soln. or adsorbed on the growing electrode. It also confirms the formation of cuprous oxide in the redn. process as the soln. pH is increased by proton redn. Moreover, when the passage of current is terminated, this technique provides evidence for the recombination of copper ions with copper metal to produce cuprous oxide on the outermost branches of the deposit.
- L15 ANSWER 103 OF 195 CA COPYRIGHT 2007 ACS on STN
- AN 128:42084 CA
- TI Local modulation of the quantum-well quasicontinuum states using charged-carrier transfer induced by intersubband transitions
- AU Bendayan, M.; Kapon, R.; Beserman, R.; Sa'ar, A.; Planel, R.
- CS Technion, Solid State Institute and Physics Department, Israel Institute of Technology, Haifa, 32000, Israel
- SO Physical Review B: Condensed Matter (1997), 56(15), 9239-9242
- By generating a local elec. field across an asym. coupled quantum-well structure and using resonant Raman spectroscopy as a probe, the authors were able to resolve two classes of continuum electronic states of energies close to the barrier height. The 1st class is related to a continuum resonant state that is located near the edge of the barrier and is extended across the barrier region but not across the coupled quantum wells. The 2nd class of continuum states is related to a quasibound resonant state that is localized above the quantum wells. Therefore, a local elec. field across the coupled quantum wells modifies the energy spectrum of the localized resonant state while keeping the delocalized resonance unaffected. In the authors' expt. the local elec. field was generated by intersubband photoexcitation of carriers from one quantum well to the other. The authors obsd. a red shift of the

quasibound resonant state due to the intersubband photoexcitation.

- L15 ANSWER 108 OF 195 CA COPYRIGHT 2007 ACS on STN
- AN 127:182647 CA
- TI Assessment of conditions influencing porous Si electroluminescence
- AU Sen, S.; Siejka, J.; Savtchouk, A.; Lagowaki, J.
- CS Center for Microelectronics Research, University of South Florida, Tampa, FL, 33620, USA
- SO Journal of the Electrochemical Society (1997), 144(6), 2230-2233
- Visible electroluminescence (EL) characteristics of **porous** Si formed on p, n, p+-n, and n+-p junction substrates were studied under **pulse** current regime. We provide exptl. proof that **porous** Si structures characterized by highest EL intensity have simultaneously highest photoluminescence (PL) intensity and lowest surface **roughness**. PL and EL can be correlated via surface **roughness**. Two types of EL instabilities are obsd.: fast, with time const. in the milliseconds range and slow, with time const. in the hours range. The fast EL instability is affected by the type of ambient and/or sample temp. during elec. excitation and probably is assocd. with the charging of the **porous** network.
- L15 ANSWER 109 OF 195 CA COPYRIGHT 2007 ACS on STN
- AN 127:114515 CA
- TI Rough electrical contact surface
- IN Lykins, James L., III
- PA Micromodule Systems, USA
- SO PCT Int. Appl., 27 pp.

PI	WO	9725455	A1	19970717	WO	1997-US86	19970110
	US	5876580	A	19990302	US	1996-586232	19960112
	US	6245445	B1	20010612	US	1999-260273	19990302
PRA:	US	1996-586232	А	19960112			

- AB A method for rendering a surface of a contact **rough** includes submerging the surface of the contact in an electroplating bath having a dissolved metal salt, and **pulsing** an elec. **current** through the contact and the bath to form a **rough** metallic structure on the surface of the contact.
- L15 ANSWER 115 OF 195 CA COPYRIGHT 2007 ACS on STN
- AN 126:39298 CA
- TI The design and implementation of a high-fidelity **Raman** imaging microscope
- AU Goldstein, S. R.; Kidder, L. H.; Herne, T. M.; Levin, I. W.; Lewis, E.
- CS Biomedical Engineering and Instrumentation Program, National Institutes Health, Bethesda, MD, 20892, USA
- SO Journal of Microscopy (Oxford) (1996), 184(1), 35-45
- The authors describe a Raman imaging microscope that produces high-fidelity, large format Raman images and Raman spectra from samples ≥1

 µm in size. Laser illumination is delivered to the object by an infinity cor. microscope objective, either by a galvanometer scanning system or a widefield fiber optic. Wavelength selection of Raman scattered emission is achieved by an acousto-optic tunable filter (AOTF), which maintains image fidelity and provides either continuous or

random wavelength selection. The collimated AOTF output is imaged 1st by a tube lens and then by a projection lens onto a cooled Si CCD array. Instrument features, including factors that det. the system's spatial and spectral resoln., and design considerations are discussed. Images and spectra of test objects and samples that demonstrate the capability of this imaging spectrometer are presented. The potential of intrinsic chem. imaging is discussed in terms of its use in the analyses of a variety of chem. and biol. samples.

- L15 ANSWER 118 OF 195 CA COPYRIGHT 2007 ACS on STN
- AN 125:70484 CA
- TI Raman imaging microscopy: A novel chemical imaging technique
- AU Kidder, Linda H.; Goldstein, Seth R.; Levin, Ira W.; Lewis, E. Neil
- CS National Institutes Health, Bethesda, MD, 20892, USA
- Proceedings of SPIE-The International Society for Optical Engineering (1996), 2655(Three-Dimensional Microscopy: Image Acquisition and Processing III), 140-147
- The authors describe a Raman imaging microscope that produces high-AΒ fidelity, large format Raman images and Raman spectra at close to diffraction-limited spatial resoln. A Si charge-coupled device (CCD) was used as a high sensitivity array detector. Wavelength selection of Raman scattered emission is achieved by an acousto-optic tunable filter (AOTF), which maintains image fidelity and provides either continuous or random wavelength selection. Laser illumination is delivered to the object by an infinity cor. microscope objective, either by a galvanometer scanning system or a widefield fiber optic. The laser scanning mechanism has higher power densities and provides Raman microprobe capabilities when stopped at a prescribed point. optic illumination scheme, however, is useful for delicate samples which might be damaged by the higher power densities generated by the point scanner mechanism and for sample alignment and system focusing. Instrument features, including factors that det. the system's spatial and spectral resoln., are discussed. Images and spectra of test objects and samples that demonstrate the capabilities of this imaging spectrometer are presented. The potential of intrinsic chem. imaging is discussed in terms of its use in the analyses of a variety of chem. and biol. samples.
- L15 ANSWER 124 OF 195 CA COPYRIGHT 2007 ACS on STN
- AN 123:73531 CA
- TI A new confocal stigmatic spectrometer for micro-Raman and microfluorescence spectral imaging analysis: Design and applications
- AU Feofanov, A.; Sharonov, S.; Valisa, P.; Da Silva, E.; Nabiev, I.; Manfait, M.
- CS Lab. de Spectroscopie Biomoleculaire, Univ. de Reims Champagne-Ardenne, Reims, 51096, Fr.
- SO Review of Scientific Instruments (1995), 66(5), 3146-58
- AB A new instrument was developed permitting confocal spectral imaging technique to be carried out with a lateral resoln. $\sim 0.3~\mu m$ and an axial resoln. $\sim 1.0~\mu m$ for specimen areas ranging from 5 × 5 to 150 × 150 μm . The modular Raman/fluorescence spectrometer was equipped with a CCD camera, microscope, motorized sample stage, and the confocal entrance

A system of galvanometer controlled mirror scanners equipped the confocal entrance chamber, allowing spectra to be accumulated up to several hundreds of points of sample in parallel, with adjustable spectral and spatial resoln. Stray light rejection property of the Raman spectrometer provides the possibility of the Raman spectral image to be recorded in the low frequency domain. A software was developed to control image accumulation, creation, and treatment. The methods of spectral anal. being applied to a multidimensional set of spectra permit the multiform spectral images to be created. To create these images, the different spectral parameters and their combination can be used, namely: intensity of characteristic bands and their ratios, width of The decompn. algorithms spectral bands, and shift of band frequencies. can be applied to two dimensional (or three-dimensional) images to deconvolute the overlapped spectra of sample components or to analyze the subtle spectral differences. The three-dimensional performance of the instrument was analyzed in the particular examples of microfluorescence study of matrixes for piezoelec. elements prodn., micro-Raman study of fluid inclusions in mineral, micro-Raman mapping of polymeric materials, and microfluorescence anal. of drug interactions with living cancer cells. The spectrometer is suitable for a wide range of applications in mineralogy, material research, solid state physics, biophysics, cellular biol., and medicine.

- L15 ANSWER 127 OF 195 CA COPYRIGHT 2007 ACS on STN
- AN 120:333613 CA
- TI The effect of process parameters on the anodic dissolution of copper into NaCl/KSCN electrolytes
- AU Gu, Z. H.; Chen, J.; Fahidy, T. Z.; Olivier, A.
- CS Dep. Chem. Eng., Univ. Waterloo, Waterloo, ON, N2L 3G1, Can.
- SO Journal of Electroanalytical Chemistry (1994), 367(1-2), 7-14
- The effect of pH, KSCN concn., NaCl concn. and imposed anode potential on oscillation patterns obsd. in the anodic dissoln. of copper into aq. solns. has been investigated. **Surface-enhanced Raman** spectroscopy of the anode surface indicates the complexity of interaction between these process parameters and the surface morphol.
- L15 ANSWER 130 OF 195 CA COPYRIGHT 2007 ACS on STN
- AN 118:243248 CA
- TI Resonance **Raman** measurement of electrochemically generated short-lived intermediates by means of a pulse electrolysis stopped flow method
- AU Oyama, Munetaka; Okada, Mikio; Okazaki, Satoshi
- CS Dep. Chem., Coll. Gen. Educ. and Grad. Sch. Hum. Inf., Nagoya Univ., Chikusa-ku, Nagoya, 464-01, Japan
- SO Journal of Electroanalytical Chemistry (1993), 346(1-2), 281-90
- Resonance Raman (RR) measurement with a pulse electrolysis stopped flow method was developed for the purpose of the measurement of electrochem. generated short-lived intermediates. In this method the soln., electrolyzed by imposing a current pulse on a column electrode, is delivered to an optical flow cell by a stopped flow technique and then the RR spectrum is obsd. at the optical cell. The RR spectrum of the triphenylamine cation radical (TPA•+), which dimerizes rapidly to produce the dimeric compd. tetraphenylbenzidine (TPB), was successfully measured selectively without any interference by the oxidn. products of

TPB generated in subsequent electron transfer reactions. The RR spectrum of TPA+ obtained had a different profile from that of the dimer cation radical (TPB+) but was quite similar to that of the dimer dication (TPB2+). This result shows the similarity between the vibrational structures of TPA+ and TPB2+, which can be explained by their canonical structures. By using the proposed method, it should become possible to observe the RR spectra of electrogenerated intermediates whose half-lives are several tens of milliseconds.

- L15 ANSWER 146 OF 195 CA COPYRIGHT 2007 ACS on STN
- AN 112:165811 CA
- TI Differential reflectance spectroscopy and **SERS** of mildly **roughenedsilver** electrodes
- AU Bryant, Mark A.; Pemberton, Jeanne E.
- CS Dep. Chem., Univ. Arizona, Tucson, AZ, 85721, USA
- SO Langmuir (1990), 6(4), 751-8
- Differential reflectance spectroscopy was used to measure the reflectivity of electrochem. roughened Ag electrodes in 0.1 M KCl and 0.1 M KCl/0.05 M pyridine. The electrodes were subjected to varying anodic current densities in double-potential-step oxidn.-redn. cycles.

A correlation exists in both systems between **SERS** intensities for both **V** (**Ag**-Cl) and pyridine ring breathing vibrations and the magnitude of the decrease in reflectivity. Surfaces that exhibit the greatest decrease in reflectivity exhibit the greatest **SERS** intensity. SEM was used to characterize surface morphol. The reflectivity spectra are interpreted in terms of absorption by large-scale **Ag roughness** features. The correlation between decrease in reflectivity and increased **SERS** intensity is proposed to be due to electromagnetic enhancement effects.

- L15 ANSWER 160 OF 195 CA COPYRIGHT 2007 ACS on STN
- AN 101:119306 CA
- TI Diffusion-controlled multisweep cyclic voltammetry. III. Deposition of silver on stationary and rotating-disk electrodes
- AU Andricacos, P. C.; Ross, P. N., Jr.
- CS Lawrence Berkeley Lab., Univ. California, Berkeley, CA, 94720, USA
- SO Journal of the Electrochemical Society (1984), 131(7), 1531-8
- An exptl. study of diffusion-controlled Ag electrodeposition was carried AΒ out in order to investigate the applicability of the model for reversible metal deposition during multisweep cyclic voltammetry. For a stationary planar electrode, excellent agreement between theory and expt. was obtained for the position of the cathodic current max. on the potential axis, as well as for the dependence of their magnitude on parameters such as sweep rate, cathodic reversal potential, and no. of applied sweeps. Anodic currents measured at the foot of the wave deviated from theor. predictions as a consequence of the small but In an effort to predict uncompensated resistance of the electrolyte. and therefore control the amt. of deposit, integral charges assocd. with each sweep were measured and successfully correlated with the parameters of the expt. At millimolar concns., deposit thicknesses of the order of up to 20 monolayers can be formed with quant. control. Expts. with a rotating-disk electrode have demonstrated that a periodic current response is obtained upon multiple sweeping, as predicted by theory.

First **sweep** and periodic **currents** normalized with respect to the limiting current could be correlated with the dimensionless sweep rate in accordance with the theor. predictions. Contrary to previous investigations, the diffusion coeff. of the **Ag** ion was detd. by liming current measurements, and the value thus obtained was subsequently used to successfully correlate stationary electrode cyclic voltammetry data. During limiting current measurements with very slow sweeps, the development of surface **roughness** was obsd. as a significant increase of the current from the const. value obtained at faster sweeps. Based on the dimensionless sweep rate, a semiempirical criterion was developed for the optimal conditions for the potentiodynamic detn. of steady-state limiting currents, the use of which may eliminate errors arising from both transient effects and surface area increase due to **roughness**.

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=> \log y
STN INTERNATIONAL LOGOFF AT 13:20:55 ON 15 NOV 2007
=> d his
     (FILE 'HOME' ENTERED AT 08:47:24 ON 15 NOV 2007)
     FILE 'CA' ENTERED AT 08:47:33 ON 15 NOV 2007
     134 S GALVANODYNAMIC
L1
L2
    7806 S POTENTIODYNAMIC
      27 S L2 AND L1
L3
L4
       O S L1 AND (MODULAT? OR ELECTROMODULAT?)
L5
       5 S L1 AND (POROSIT? OR PORE OR POROUS)
      72 S L1 AND (POLARIZATION CURVE OR ELECTROREDUCTION OR
1.6
         GALVANODYNAMIC/TI, ST, IT)
L7
      51 S L1-2 AND ADATOM?
\Gamma8
     140 S L3-7
L9
     134 S L8 AND PY<2004
L10
     6 S L8 NOT L9
L11
       1 S L2/IT AND L10
=> d bib, ab, kwic 19 1-134
L9
     ANSWER 5 OF 134 CA COPYRIGHT 2007 ACS on STN
     136:392351 CA
ΑN
     Electrokinetic behavior of gold alloy and composite plating baths
ΤI
     Bozzini, B.; Cavallotti, P. L.; Giovannelli, G.
ΑU
     INFM, Dipartimento di Ingegneria dell'Innovazione, Universita di Lecce,
CS
     Lecce, Italy
     Metal Finishing (2002), 100(4), 50,52-54,56-60
SO
     The electrochem. processes involved in Au-Cu and Au-Cu-Cd alloy and
AB
     composite deposition were studied. Two kinds of Au-Cu electrodeposition
     baths were investigated: an alk. cyanide bath and an acidic EDTA bath.
     For comparison an alk. cyanide Au-Cu-Cd bath was also used. The ceramic
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material was B4C with particles of an av. diam. of 2.52 μ m and median

diam. of 0.6 μ m. Microstructures were studied with SEM and XRD and

potentiodynamic measurements were made on baths with and without

electrochem. investigations on baths not contg. particles were performed by **potentiodynamic** and **galvanodynamic** measurements. Galvanostatic and

dispersion of ceramic particles. The high free-cyanide cyanoalkaline baths displayed a sigmoidal potentiodynamic behavior and a hysteretic galvanodynamic behavior. Metallog. cross sections of deposits obtained from such baths showed a laminar structure with an alternation of Auenriched and Au-depleted regions under cell potential control. current control the deposits had a homogeneous contribution in both branches of the hysteresis loop. Embedding of nonconductive particles in all the investigated baths for alloy deposition correlated with an increase of the content of the less noble alloying element. nonhysteretic alloy deposition baths (EDTA Au-Co and cyanide Au-Cu-Cd) such a phenomenon was the only obsd. consequence of dispersing particles while in hysteretic baths (cyanoalkaline Au-Cu) in addn. to this phenomenon compositional heterogeneities were present. The phenomenon of "tails" and "crests" formation in hysteretic baths loaded with insulating particles took the place of the layering which could be obsd. by operating baths not contg. particles under cell potential control. Both phenomena could be explained with the same kind of instability.

- L9 ANSWER 8 OF 134 CA COPYRIGHT 2007 ACS on STN
- AN 135:324247 CA
- TI Potential Oscillations and S-Shaped **Polarization Curve** in the Continuous Electro-oxidation of CO on Platinum Single-crystal Electrodes
- AU Koper, Marc T. M.; Schmidt, Thomas J.; Markovic, Nenad M.; Ross, Philip
- CS Schuit Institute of Catalysis Laboratory of Inorganic Chemistry and Catalysis, Eindhoven University of Technology, Eindhoven, 5600, Neth.
- SO Journal of Physical Chemistry B (2001), 105(35), 8381-8386
- The occurrence of an S-shaped polarization curve in a simple model for AΒ the continuous electrochem. oxidn. of CO on a platinum electrode is In the model, the S-shaped polarization curve is caused by the competitive Langmuir-Hinshelwood mechanism between surface-bonded CO and OH. The reaction is studied exptl. on single-crystal platinum rotating disk electrodes in perchloric and sulfuric acid soln., and it is shown that the voltammetry is in good agreement with the model predictions. When studied under current-controlled conditions, a fast galvanodynamic scan indeed suggests the existence of the S-shaped polarization curve. At lower scan rates, however, irregularities and small-amplitude irregular fluctuations or oscillations in potential are obsd. Very regular potential oscillations under current-controlled conditions are obsd. only on Pt(111) in sulfuric acid. The possible origin of these irregularities and oscillations is discussed in relation to the existing theories of electrochem. instabilities.
- L9 ANSWER 14 OF 134 CA COPYRIGHT 2007 ACS on STN
- AN 129:251658 CA
- TI Electrodeposition of hard magnetic alloys from non-aqueous electrolytes
- AU Holstein, N.; Juttner, K.
- CS Karl-Winnacker-Institut der DECHEMA e. V., Frankfurt am Main, D-60486, Germany
- Proceedings Electrochemical Society (1998), 97-27 (Fundamental Aspects of Electrochemical Deposition and Dissolution Including Modeling), 240-252
- AB The electrochem. deposition of Sm-Co layers on platinum and copper

substrates was studied using the aprotic electrolytes formamide + SmCl3 + CoCl2 + KCl and propylene carbonate + Sm(NO3)3.6H2O + Co(NO3)2.6H2O + Bu4NPF6 by **potentiodynamic** and **galvanodynamic** measurements dependent on different system parameters. The properties of the layers were detd. by SEM, EDX, XRD and magnetic measurements. The Sm/Co ratio of the galvanic deposits depends not only on the compn. of the electrolyte, but also on the deposition conditions, e.g. potentiostatic or galvanostatic polarization, convection, supporting electrolyte, etc. So far layers with the best properties were obtained under galvanostatic conditions from a propylene carbonate soln. with a mole ration Sm:Co = 3:1. These layers have metallic characteristics and show a distinct hysteresis in the magnetization loop.

- L9 ANSWER 19 OF 134 CA COPYRIGHT 2007 ACS on STN
- AN 126:49747 CA
- TI Electrochemical AC etching of aluminum foils in hydrochloric acid electrolytes
- AU Jeong, Jae Han; Kim, Sung Su; Kim, Hyun Gi; Choi, Chang Hee; Lee, Dong Nyung
- CS Samsong Research Institute, Sam Young Electronics Co., Ltd., Seong Nam, 462-120, S. Korea
- SO Materials Science Forum (1996), 217-222(Pt. 3, Aluminium Alloys, Pt. 3), 1565-1570
- AB The electrochem. a.c. etching behavior of an Al foil was studied in 1.5 M HCl soln. at different temps. (35-60°), and varying current frequencies 1-60 Hz. The **galvanodynamic polarization curves** were recorded and the microstructures were investigated by SEM. At a frequency of 10 Hz optimal etching occurred (**porous** and homogeneous etched layers were formed). Below that frequency macro-thinning took place and above that frequency irregular local corrosion was obsd. The etch pit size decreased with increasing frequency.
- L9 ANSWER 60 OF 134 CA COPYRIGHT 2007 ACS on STN
- AN 104:35524 CA
- TI Potentiodynamic electrodeposition of paint (EDP)
- AU Beck, Fritz; Guder, Harald
- CS FB6-Elektrochem., Univ. GH-Duisburg, Duisburg, D-4100/1, Fed. Rep. Ger.
- SO Journal of Applied Electrochemistry (1985), 15(6), 825-36
- Potentiodynamic electropainting at a rotating iron disc electrode was AB investigated with 3 different EDP resins, 2 anodic of the acrylate type and 1 cathodic of the epoxide type, and a wide variation of conditions. Voltage scan rate (vs = 1 to 200 Vs-1), voltage range (40 to 200 V) and electrode rotation speed (n = 60 and 1000 rpm) were the most important The (cyclic) voltammetric curves obtained generally exhibit 3 characteristic features: (1) the current rises steeply at the start of Bath resistance transforms the potentiodynamic curve simultaneously into a galvanodynamic curve. After a transition time, t, a crit. pH is attained at the phase boundary and electrocoagulation occurs. This leads to a rapidly decreasing c.d. The sharp c.d. max. thus established has a peak voltage, Up, which increases with vs according to the relation log Up \sim 1/3 log vs in accordance with theory. (2) At high voltages, a limiting c.d. is obsd., increasing with

the square root of vs. This could be quant. interpreted in terms of dynamic growth of film thickness governed by Ohmic ion transport in the film. The preceding part of the U/j curve declines with j \sim t-1/2, which indicates the prevalence of space charge effects. (3) Ohmic lines are measured in the course of the first reverse scan and in all quasi steady state follow up cycles. They are flatter by a factor of 1000 in regard to the initial Ohmic line and reflect low voltage Ohmic behavior of the EDP-film. At high voltages pos. current deviations occur due to Child's law. The curves can be measured easily and reproducibly. Due to their salient features it is proposed to use them for characterization of EDP-paints.

- L9 ANSWER 128 OF 134 CA COPYRIGHT 2007 ACS on STN
- AN 80:22086 CA
- OREF 80:3601a,3604a
- TI Formation of finely divided precipitates during reduction of metals on mercury or amalgamated electrodes
- AU Geinrikhs, K. Ya.; Gladyshev, V. P.; Babkin, G. N.
- CS USSR
- SO Trudy Instituta Khimicheskikh Nauk, Akademiya Nauk Kazakhskoi SSR (1973), 35, 33-48
- LA Russian
- The conditions of formation of finely divided deposits on Hg and amalgam AΒ electrodes was dependent on the metal nature, compn. of the electrolyte, and parameters of electrolysis. Tests were conducted for Cd, Pb, Bi, and Ta and for Cu, Zn, In, Sn, Fe, and Co by the method of plotting potentiostatic and galvanodynamic polarization curves. The forming finely divided deposits on Hg surface did not depend on the metal soly. in Hg; their formation started at a specific electrode potential for each metal, irrespective on the concn. of the metal in the electrolyte The conditions of formation of finely divided deposits of and amalgam. metals were similar for solid and liq. electrodes; this was indicative of a single formation mechanism of these deposits on solid and liq. electrodes. The mechanism of formation of these deposits during the electroredn. of metals was independent of the material and aggregate state of the electrode as well as on the compn. of the soln.
- L9 ANSWER 134 OF 134 CA COPYRIGHT 2007 ACS on STN
- AN 72:62189 CA
- OREF 72:11360h,11361a
- TI Automatic polarization apparatus for electrochemical corrosion studies
- AU Henry, W. D.; Wilde, Bryan Edmund
- CS Appl. Res. Lab., U. S. Steel Corp., Monroeville, PA, USA
- SO Corrosion (Houston, TX, United States) (1969), 25(12), 515-19
- AB Statistical alloy development programs using electrochem. screening techniques, require facilities for precision polarization data; presently available equipment and methods are not entirely satisfactory. Modifications were made to readily available com. equipment to improve the sensitivity and reproducibility significantly. A detailed description is given of the production of an app. that automatically measures and records anodic and cathodic **polarization curves** over an

applied potential range of ± 2.0 V. Traverse rates between 2 \times 10-3 and

3 × 104 V/hr are attainable and can be used to polarize electrodes through 0 V (with respect to the reference electrode) without manual switching. A special switch is described for using the basic electronic potentiostat as a const. current or const. voltage source by manual selection. The results obtained from 3 typical polarization expts.: (1) potentiodynamic anodic polarization, (2) galvanodynamic cathodic polarization, and (3) galvanodynamic linear polarization of AISI type 304 stainless steel in H-satd. N H2SO4 at 25° showed the performance of the app. to be equal to or superior to that of conventional manual procedures. Errors from curve plotting are eliminated.

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